Global tender for Sputtering targets

This is an RFQ (Request for Quote) for Supply of Sputtering targets to be used for metal contacts in microelectronics applications

Procedure:

- 1. Vendors will be required to submit a quote, containing details of the Principal Supplier with CIF, Bengaluru price.
- 2. The technical description should take into account the following requirements and information that has been provided:

Target Spec	Quantity
 Circular gold (Au) sputter target, 76.2 mm diameter, 3 mm thickness, tolerance +/- 0.2 mm, purity 99.99 % or better. 	2 Nos.
 2. Circular Platinum (Pt) sputter target, 76.2 mm diameter, 3 mm thickness, tolerance +/- 0.2 mm, purity 99.99 % or better. 	2 Nos.

- 3. The target is used for high-tech research work by research scholars. The vendor should have supplied the above material either to CeNSE, Indian Institute of Science, Bangalore or other microelectronics fabrication unit of repute. Proof of the same should be attached.
- 4. The deadline for submission of quotes is the 21st Dec 2021, 5:30 pm Indian Standard Time. Proposals should arrive at GF20, NNFC Office, Centre for Nano Science and Engineering, Indian Institute of Science, Bangalore 560012, India.

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